

Electronic Patent Application Fee Transmittal

Application Number:	10591718								
Filing Date:	05-Sep-2006								
Title of Invention:	Positive-type resist composition for liquid immersion lithography and method for forming resist pattern								
First Named Inventor/Applicant Name:	Keita Ishiduka								
Filer:	Nichole Elizabeth Martiak/Kathleen Goodhand								
Attorney Docket Number:	1608-7 PCT/US								
Filed as Large Entity									
U.S. National Stage under 35 USC 371 Filing Fees									
<table border="1" style="width: 100%; border-collapse: collapse;"> <thead> <tr> <th style="width: 30%;">Description</th> <th style="width: 15%;">Fee Code</th> <th style="width: 15%;">Quantity</th> <th style="width: 15%;">Amount</th> <th style="width: 15%;">Sub-Total in USD(\$)</th> </tr> </thead> </table>					Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)					
Basic Filing:									
Pages:									
Claims:									
Claims in excess of 20	1615	2	52	104					
Miscellaneous-Filing:									
Petition:									
Patent-Appeals-and-Interference:									
Post-Allowance-and-Post-Issuance:									
Extension-of-Time:									

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Request for continued examination	1801	1	810	810
Total in USD (\$)				914